



# DEPARTMENT OF COMMERCE **Patent and Trademark Office**

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APPLICATION NO.	FILING DATE		FIRST NAMED INVENTOR		ATTORNEY DOCKET NO.
09/478.812 01/	07/00 SUGA	ОМ	Y	SON-1718	
_	ing.	M92/0119	· ¬		EXAMINER
Ronald P Kananen Esq			LEE,E		
Rader Fishman & Grauer				ART UNIT	PAPER NUMBER
The Lion Building 1233 20th Street		01	2815		
Washington DC 20036				<b>DATE MAILED</b> 01/19/01	:

Please find below and/or attached an Office communication concerning this application or proceeding.

**Commissioner of Patents and Trademarks** 

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Office Action Summany			ion No.	Applicant(s)				
			12	SUGANO ET AL.				
Office Action Summary		Examine	r	Art Unit				
		Eugene	Lee	2815				
Period fo	The MAILING DATE of this communication Reply	n appears on the	cover sheet with the co	orrespondence ac	ldress			
THE N - Exten after: - If the - If NO - Failur - Any re	DRTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICAT sions of time may be available under the provisions of 37 SIX (6) MONTHS from the mailing date of this communicate period for reply specified above is less than thirty (30) day period for reply is specified above, the maximum statutory to the toreply within the set or extended period for reply will, be performed by the Office later than three months after the displacement of the patent term adjustment. See 37 CFR 1.704(b).	TION.  CFR 1.136 (a). In no etion.  s, a reply within the start period will apply and ways statute, cause the ap	vent, however, may a reply be tir tutory minimum of thirty (30) day vill expire SIX (6) MONTHS from plication to become ABANDONE	nely filed s will be considered tim the mailing date of this D (35 U.S.C. § 133).	ely. communication.			
1)⊠	Responsive to communication(s) filed of	n <u>07 January 20</u>	<u>000</u> .					
2a)[_	This action is <b>FINAL</b> . 2b)	☐ This action is	s non-final.					
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Dispositi	on of Claims							
4) 🖂	Claim(s) 1-74 is/are pending in the appl	ication.			,			
4a) Of the above claim(s) <u>1-10,13-16,19-26,29-38,41-52,55-62 and 66-72</u> is/are withdrawn from consideration.								
5)	Claim(s) is/are allowed.			1				
6)[	6) Claim(s) <u>11,12,17,18,27,28,39,40,53,54,63-65,73 and 74</u> is/are rejected.							
7)	Claim(s) is/are objected to.							
8) 🗌	Claims are subject to restriction	and/or election r	equirement.					
Application	on Papers							
9)⊠	The specification is objected to by the Ex	kaminer.	,					
10)	The drawing(s) filed on is/are objective.	ected to by the E	xaminer					
11) The proposed drawing correction filed on is: a) approved b) disapproved.								
12) The oath or declaration is objected to by the Examiner.								
Priority u	nder 35 U.S.C. § 119							
13)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d).								
a)⊠ All b)□ Some * c)□ None of:								
	1.⊠ Certified copies of the priority doc	uments have bee	en received.					
2. Certified copies of the priority documents have been received in Application No								
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).								
* See the attached detailed Office action for a list of the certified copies not received.								
14) ☐ Acknowledgement is made of a claim for domestic priority under 35 U.S.C. & 119(e).								
Attachment	(s)							
	ce of References Cited (PTO-892)		18) Interview Summar	y (PTO-413) Paper I	No(s)			
16) Notic	ce of Draftsperson's Patent Drawing Review (PTO- mation Disclosure Statement(s) (PTO-1449) Paper		19) Notice of Informal 20) Other:	Patent Application (I	PTO-152)			

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#### **DETAILED ACTION**

### Specification

1. The disclosure is objected to because of the following informalities: on page 3, line 20, the word "future" lacks antecedent basis; on page 5, line 3, "so improved that expected" is unclear; on page 14, line 11, the word "of" is missing after "each"; on page 79, line 6, the word "convert" is spelled incorrectly.

Appropriate corrections to these and all other clerical errors are required.

### Claim Objections

- 2. Claims 12, 18, 28, 40, 54, 74 are objected to because of the following informalities: on line 1 of said claims, the word "substrate" should be plural. Appropriate corrections are required.
- 3. Claims 64 is objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form. Claim 64 recites the same limitation (i.e. semiconductor film .... gate insulating film) in claim 63; therefore, it does not add any limitations to claim 63.

## Claim Rejections - 35 USC § 112

4. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

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5. Claims 11, 12, 17, 18, 27, 28, 39, 40, 53, 54, 63-65, 73, and 74 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

- a. On line 10 of claim 17 (and also claim 18), it is indefinite whether the substrate or the plural units are converted to polycrystalline silicon. The Office suggests that the applicant includes "the substrate" or "the plural units" after the word "convert" for a better clarification of the claim.
- b. Claims 11, 12, 17, 18, 27, 28, 39, 40, 53, 54, 63-65, 73, and 74 does not define what constitutes as "relatively small" and "relatively large" in the lines 7, 11 of claim 11, for example. This is a relative term which renders the claim indefinite because it would be unclear to one of ordinary skill in the art at the time of invention to understand what "relatively small" is, since it is being defined relative to something not stated in the claim.
- c. Claims 39, 40 contain the recitation "modified." This is a relative term which renders the claim indefinite because it would be unclear to one of ordinary skill in the art at the time of invention to understand what the polycrystalline silicon is "modified" relative to. Therefore, the claims do not provide an objective standard which adequately defines the metes and bounds of the claims.
- 6. Claims 27 and 28 recite the limitation "semiconductor thin films" in line 13 and line 17 of respective claims. There is insufficient antecedent basis for this limitation in the claim.

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### Claim Rejections - 35 USC § 102

7. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 8. Insofar as definite, claims 11, 39, 53, 63, 64, 73 are rejected under 35 U.S.C. 102(b) as being anticipated by Zhang et al. '291. Zhang discloses a thin film semiconductor device comprising a polycrystalline silicon film with "relatively large particle diameter" and characteristics that are made uniform. See, for example, column 3, line 67.
  - a. Zhang does not explicitly state the parts of the thin film semiconductor device

    (i.e. gate insulating film, gate electrode, etc.), however, these parts are

    conventionally found in thin film transistors. See the *Prior Art* cited below, for
    an example.
  - b. Also, see *Product by Process Limitation* below.

## Claim Rejections - 35 USC § 103

- 9. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 10. Insofar as definite, claims 12, 18, 28, 40, 54, 65, 74 are rejected under 35 U.S.C. 103(a) as being unpatentable over Zhang et al. '291 as applied to claims 11, 39, 53, 63, 64, 73 above,

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and further in view of Tanaka et al. '744. Zhang does not disclose the thin film transistor as part of a display device comprising a pair of substrates adhered with an electrooptical substance and a presence of counter, pixel electrodes, etc. However, it was well known in the art at the time of invention that thin film transistors are integral to display or LCD devices (for example, see abstract and column 1, lines 8-17 of Tanaka). Therefore, it would have been obvious to one of ordinary skill in the art at time of invention to use the TFT polycrystalline films of Zhang's invention in the thin film transistors found in, for example, Tanaka's display devices since thin film transistors are conventionally used in display devices.

- a. Note, for example, in FIG. 3, Tanaka shows a display device with the two substrates 12, 10, liquid crystal 200, counter electrodes 170r, 170g, pixel electrodes 150 and thin film transistor 101. These components are conventionally found in LCD display devices.
- b. Claim 18 discloses the claimed invention except for the plural units. It would have been obvious to one having ordinary skill in the art at the time of the invention was made to duplicate the units since it has been held that mere duplication of the essential working parts of a device involves only routine skill in the art. In re Japikse, 86 USPQ 70.
- c. Claim 28 discloses the claimed invention except for "said semiconductor thin films are accumulated." It would have been obvious to one having ordinary skill in the art at the time of the invention was made to duplicate and accumulate the semiconductor thin films since it has been held that mere duplication of the

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essential working parts of a device involves only routine skill in the art. In re Japikse, 86 USPQ 70.

- Insofar as definite, claim 17 is rejected under 35 U.S.C. 103(a) as being unpatentable over Zhang et al. '291. Claim 17 discloses the claimed invention except for the plural units. It would have been obvious to one having ordinary skill in the art at the time of the invention was made to duplicate the units (and form more than one polycrystalline unit) since it has been held that mere duplication of the essential working parts of a device involves only routine skill in the art. In re Japikse, 86 USPQ 70.
- 12. Insofar as definite, claim 27 is rejected under 35 U.S.C. 103(a) as being unpatentable over Zhang et al. '291. Claim 27 discloses the claimed invention except for "said semiconductor thin films are accumulated." It would have been obvious to one having ordinary skill in the art at the time of the invention was made to duplicate and accumulate the semiconductor thin films since it has been held that mere duplication of the essential working parts of a device involves only routine skill in the art. In re Japikse, 86 USPQ 70.

#### Prior Art

13. The prior art of made of record and not relied upon is considered pertinent to applicant's disclosure. See, for example, Zhang et al. '244 (in FIG. 4) where it shows the gate oxide, gate electrode and semiconductor thin film, parts of which are all conventional to a thin film transistor.

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### **Product-by-Process Limitations**

While not objectionable, the Office reminds Applicant that "product by process" limitations in claims drawn to structure are directed to the product, per se, no matter how actually made. *In re Hirao*, 190 USPQ 15 at 17 (footnote 3). See also, *In re Brown*, 173 USPQ 685; *In re Luck*, 177 USPQ 523; *In re Fessmann*, 180 USPQ 324; *In re Avery*, 186 USPQ 161; *In re Wethheim*, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); *In re Marosi et al.*, 218 USPQ 289; and particularly *In re Thorpe*, 227 USPQ 964, all of which make it clear that it is the patentability of the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or otherwise. Note that applicant has the burden of proof in such cases, as the above case law makes clear. Thus, no patentable weight will be given to those process steps which do not add structural limitations to the final product.

All the claims recite limitations that do not offer any *structural* variation to the *final* product. Therefore, any language, such as "formed by forming ...... irradiating ...... with an energy beam" and "irradiate said region at a time by a single shot irradiation" in claim 11, for example, are given no patentable weight. The language here only recites methods of forming the final product (either a thin film semiconductor device or display device). Therefore, the only limitations that the Office finds patentable are limitations that are part of a *final structure*, regardless of any methods or intermediate structures that are present and recited in the claims.

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#### INFORMATION ON HOW TO CONTACT THE USPTO

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eugene Lee whose telephone number is 703-305-5695. The examiner can normally be reached on M-F 8-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on 703-308-1690. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

Eugene Lee January 14, 2001

> EDDIE C. LEE PRIMARY EXAMINER